

Comparison of commercially available
MBIX resins for UPW production using
measuring techniques described in
SEMI C93 and beyond

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CT Associates, Inc.



AGENDA

- 1) Problem statement
- 2) Test methods
- 3) Test results
- 4) Comparison of Mixed Bed Ion Exchange (MBIX) resins
- 5) Further findings from the experiments: What combines all resins
- 6) Key takeaways

PROBLEM STATEMENT

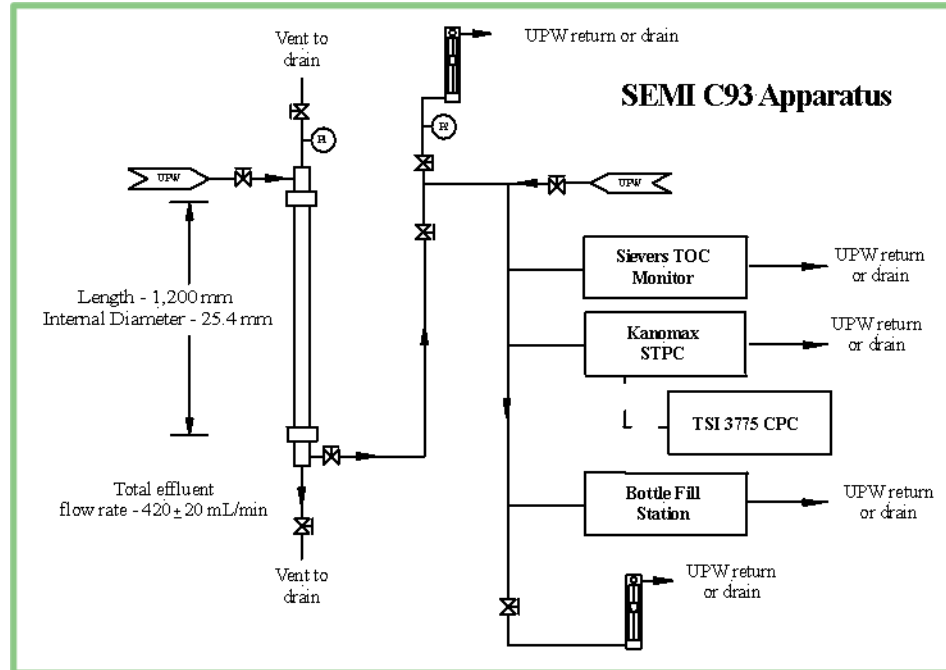
- Mixed Bed Ion Exchange (MBIX) resins are a key component to produce Ultrapure Water in a Polishing System.
- While MBIX resins are designed to remove ions from the water, all MBIX resins also shed ions, organics, particles and particle precursors. In fact, **it is not so much the ion removal rate that defines the quality of the water produced with a Mixed Bed in a Polishing System, but the various shedding rates (metals, particles, organics).**
- The focus of this presentation is on a comparative study of the different resins rather than on absolute values.

TEST METHODS

Off-line



4) CTA Sequential Spin Coating (SSC) / UNISERS Surface Enhanced Particle Sizing (SEPS)



7) CTA Jasco 6600 Fourier-Transform Infrared Spectroscopy (FTIR)



1) Static leach analysis of the resin per SEMI C93-0522 with 3:1 UPW: 35% HCl by ICP/MS.

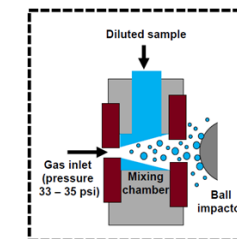
Online



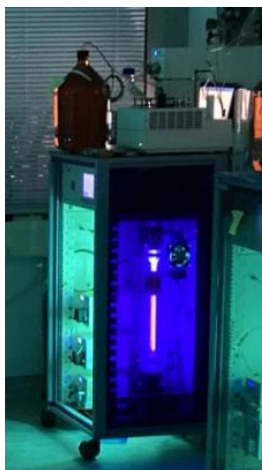
5) CTA Sievers 500 RL Total Organic Carbon (TOC)



3) CTA Kanomax FMT STPC Nanoparticle Analyzer



2) CTA Ultrafine Nebulizer/ TSI Model 3775 CPC Nanoparticle Analyzer



6) DOC-Labor LC-OCD-OND Organic Speciation

TEST METHODS

Static HCl leach test

1. Metals analysis

Dynamic IX resin rinse test

2. Particles > 4 nm were measured using ultrafine nebulization supplying a TSI 3775 4 nm condensation particle counter (CPC)
3. Particles > 7, 12 and 18 nm were measured using a Kanomax FMT Model 9010 Scanning Threshold Particle Counter (SEMI C93 presents particle analysis on MBIX resin for particles > 10 nm)
4. Measuring the accumulation and distribution of nanoparticles on wafer surfaces, involving a combination of sequential spin coating (SSC) and surface enhanced particle sizing (SEPS) using a UNISERS surface inspection. The lower particle size detection limit is 8 nm
5. TOC was measured using a Sievers Model 500 RL TOC analyser
6. Enhanced organics speciation with LC-OCD-OND analysis by DOC-Labor Huber with a DL of 5 ppt C (lower DL compared to analyses presented in SEMI C93)
7. Qualitative analysis of non-volatile residue chemistry from FTIR -ATR spectra of MBIX (Effluent - Influent) and comparisons to the other measuring techniques

Method according to SEMI C93
SEMI C93 method adapted
New method

TEST RESULTS - METALS

Total Metals concentration

Resins 1 – 6 tested in the rev. of SEMI C93 released 2019

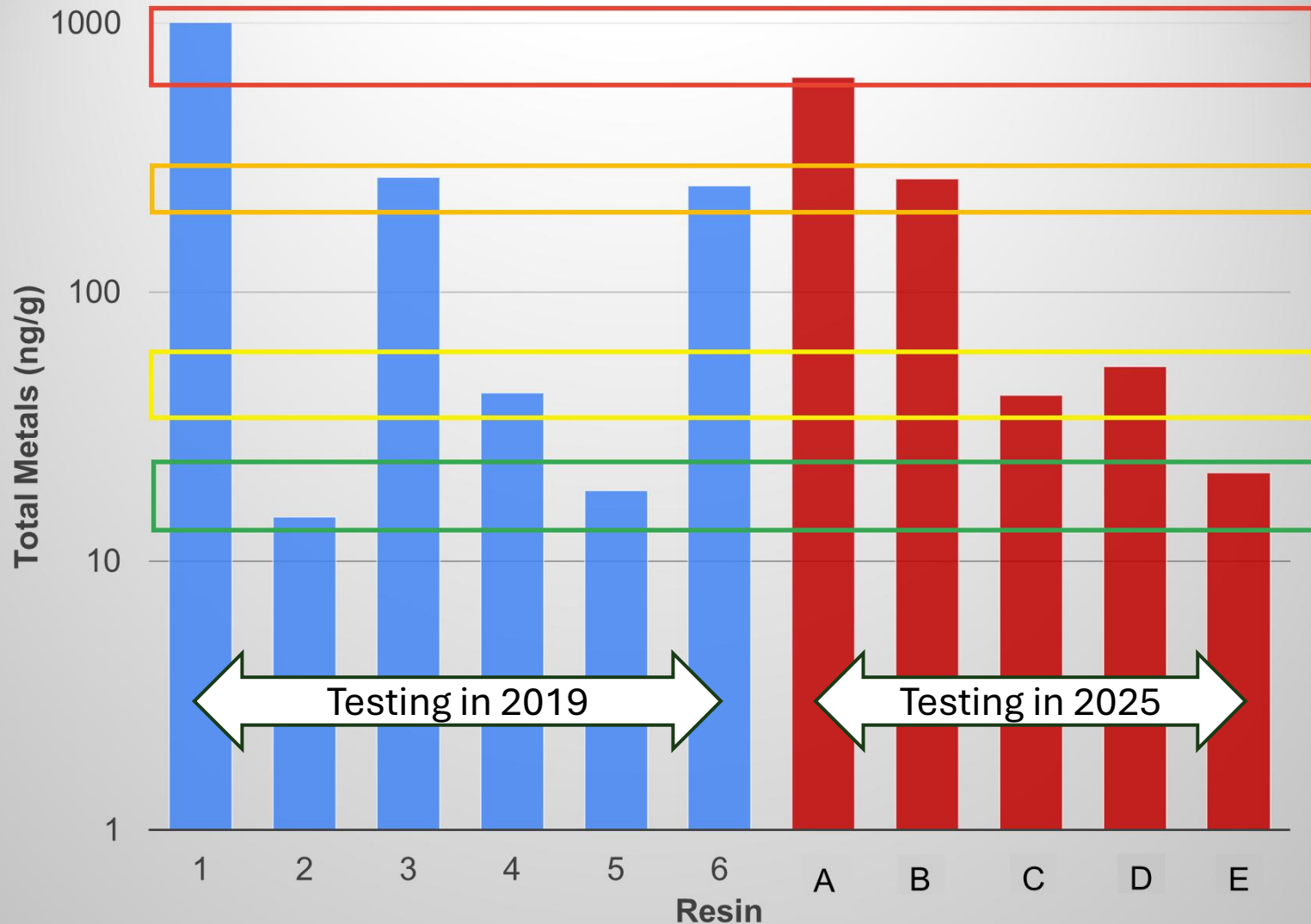


Resins A – E tested in 2025



Results

- ⇒ We found a factor 30 between resins A to E for total metals content.
- ⇒ We found the total metal content to be in the same range compared to the last testing 2019.



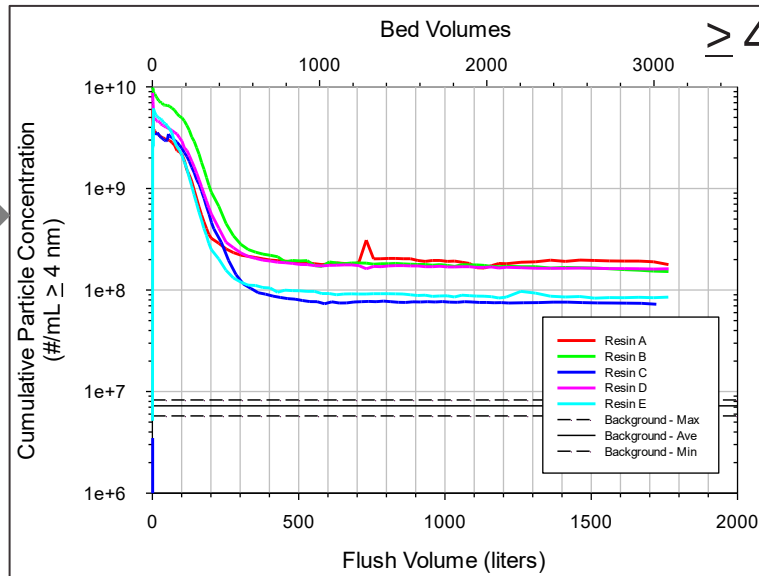
TEST RESULTS – ONLINE PARTICLES

Particles ≥ 4 nm for resins A-E measured with a CPC

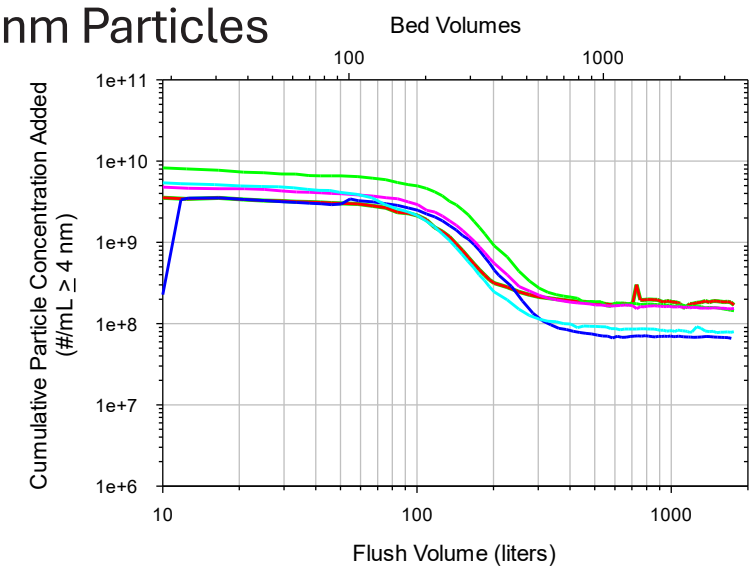


Result

=> We found a factor 2.4 between resins A to E for particles ≥ 4 nm



≥ 4 nm Particles

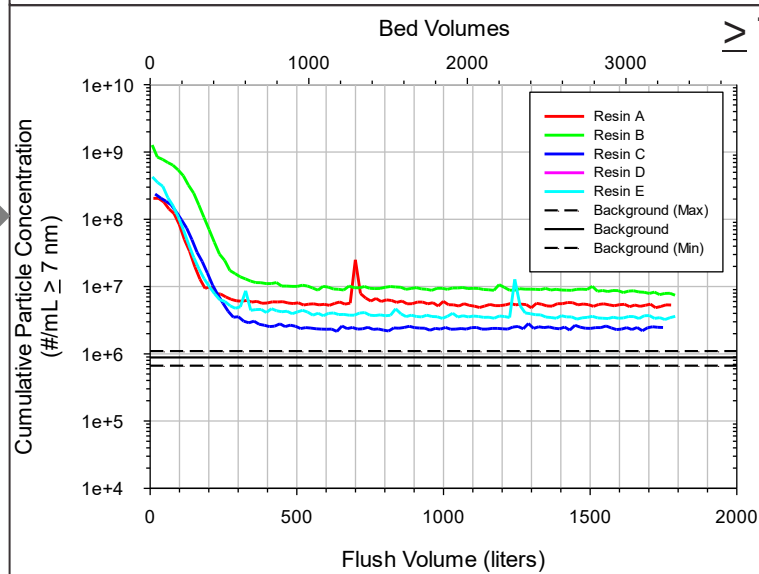


Particles ≥ 7 nm for resins A-E measured with a STPC

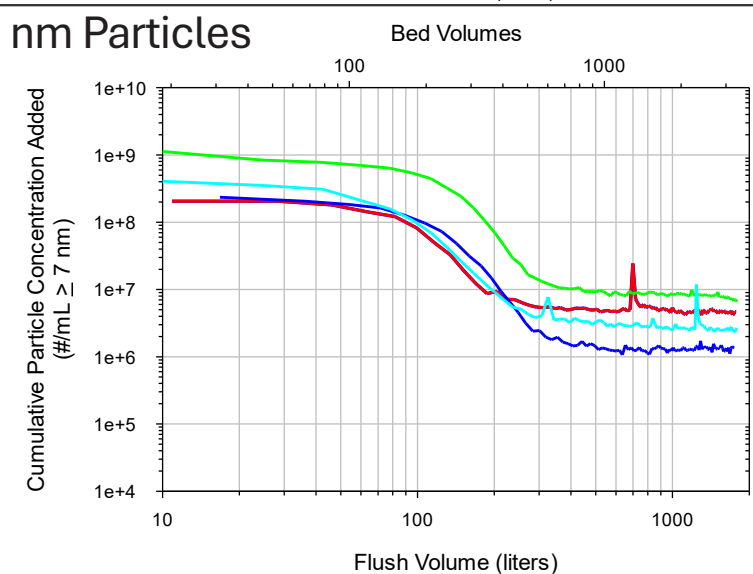


Result

=> We found a factor 3.3 between resins A to C, E for particles ≥ 7 nm



≥ 7 nm Particles



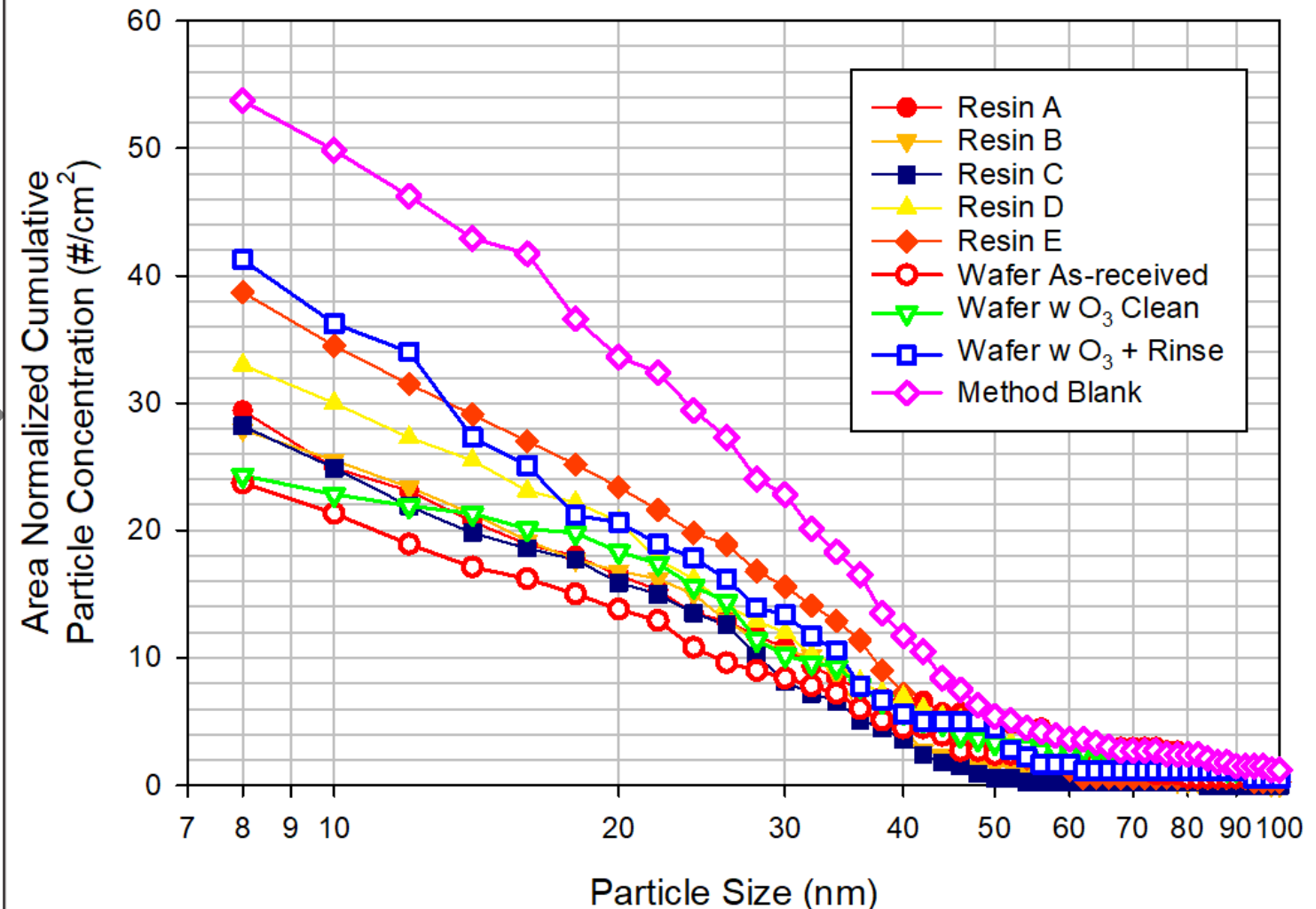
TEST RESULTS – PARTICLES ON WAFER

Particles ≥ 8 nm on wafer surfaces, involving a combination of sequential spin coating (SSC) and surface enhanced particle sizing (SEPS) using a UNISERS surface inspection tool



Observations:

- Increase handling steps increase background levels.
- Unable to detect a correlation between particle precursor concentration to on-wafer defects likely due to the low signal-to-noise.



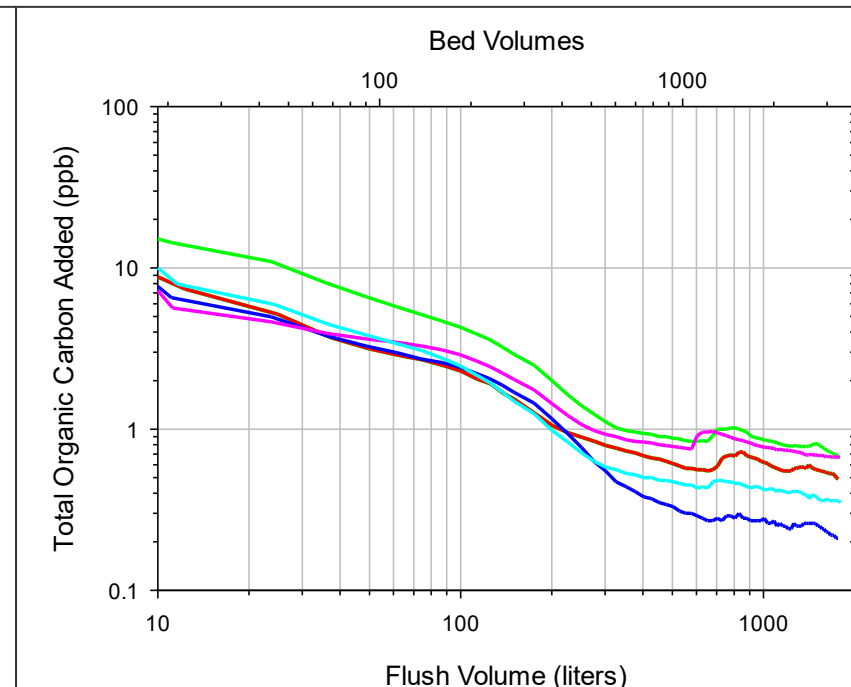
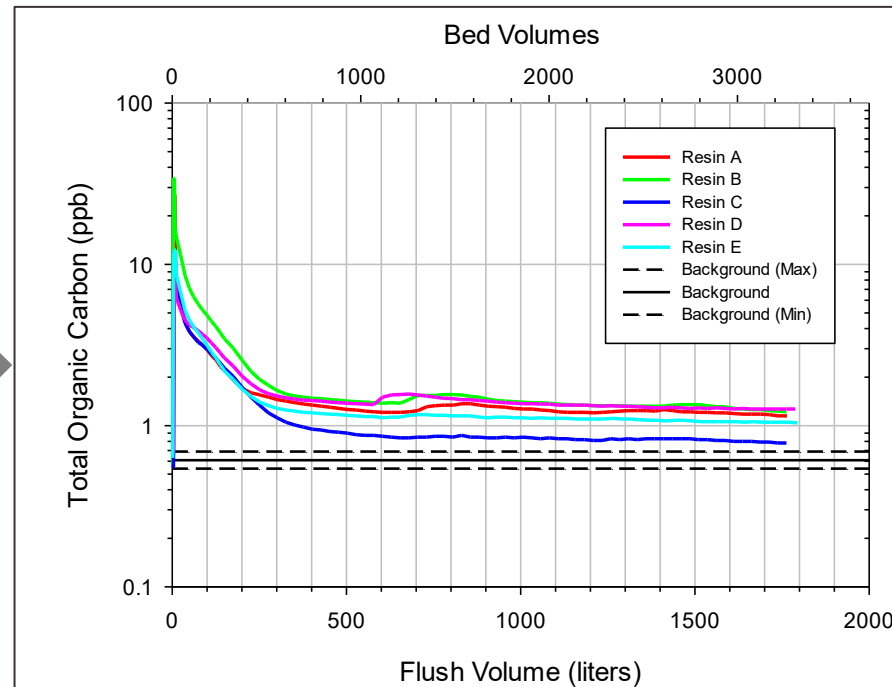
TEST RESULTS – ONLINE TOC

Online TOC after 3,200 bed volumes have passed through the resin column



Result

=> We found a factor **1.6** for the final water quality after rinse down between resins A to E

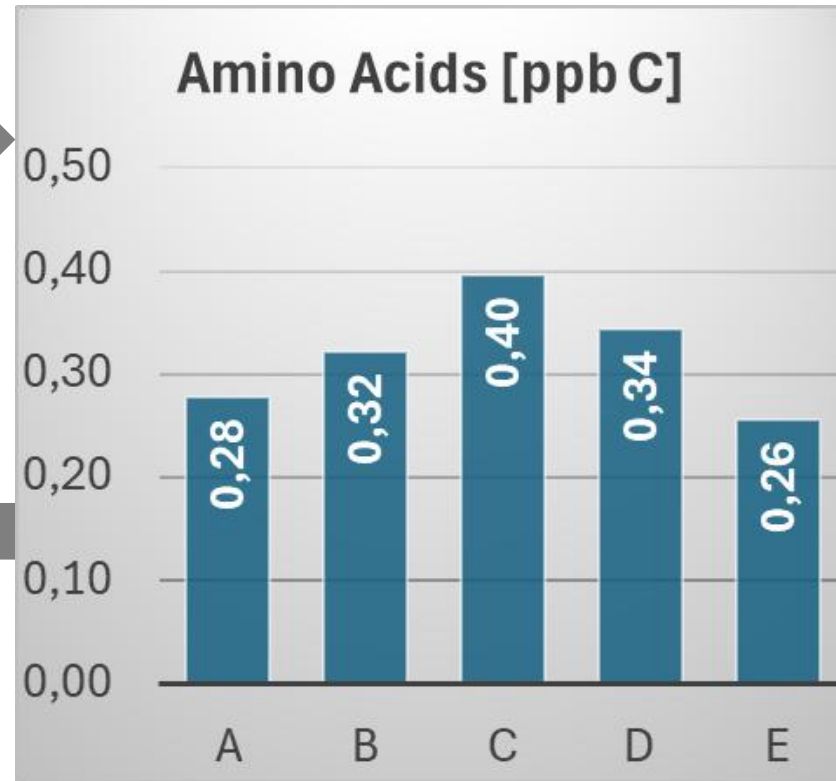


TEST RESULTS – LC-OCD

Amino Acids from LC-OCD

Result

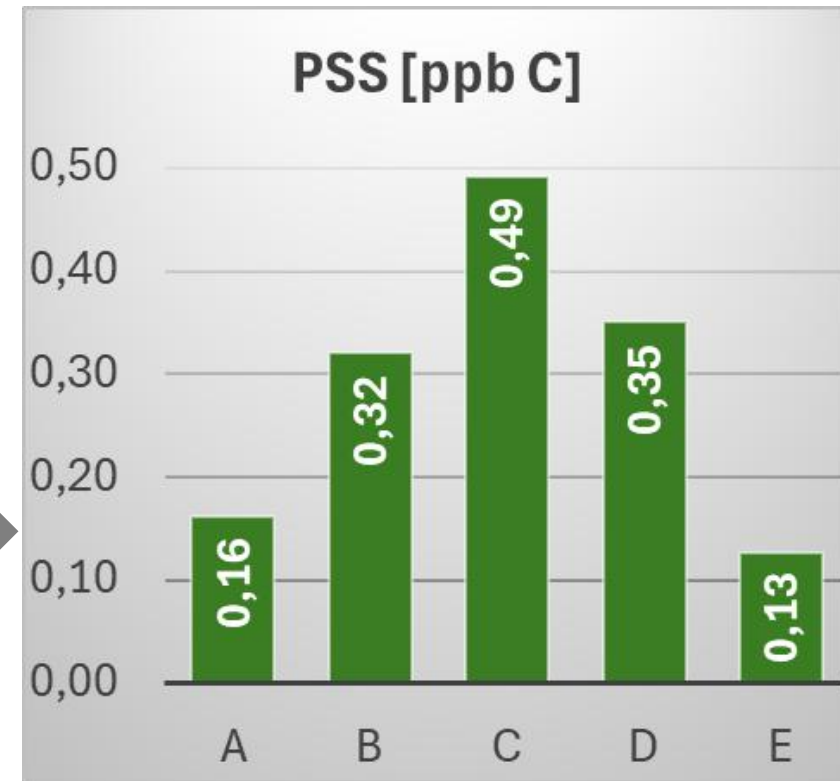
=> We found a factor 1.55
between resins A to E



PSS (Polystyrene sulfonate)
from LC-OCD

Result

=> We found a factor 3.7
between resins A to E



RESIN COMPARISON (QUALITATIVE)

	Metals	Particles			Organics			Result
Variability	30	2.4	3.3		1.60	1.55		
Test	M1	P1	P2	av. P	O1	O2	av. O	av. M/O/P
Resin A	0	1	1	1	1	3	2	0.8
Resin B	1	1	0	0.5	0	1	0.5	0.8
Resin C	2	3	3	3	3	0	1.5	2.0
Resin D	2	1	*	1	1	1	1	1.5
Resin E	3	2	2	2	2	3	2.5	2.7

* no data

x3

x1

x2

Weighted Average

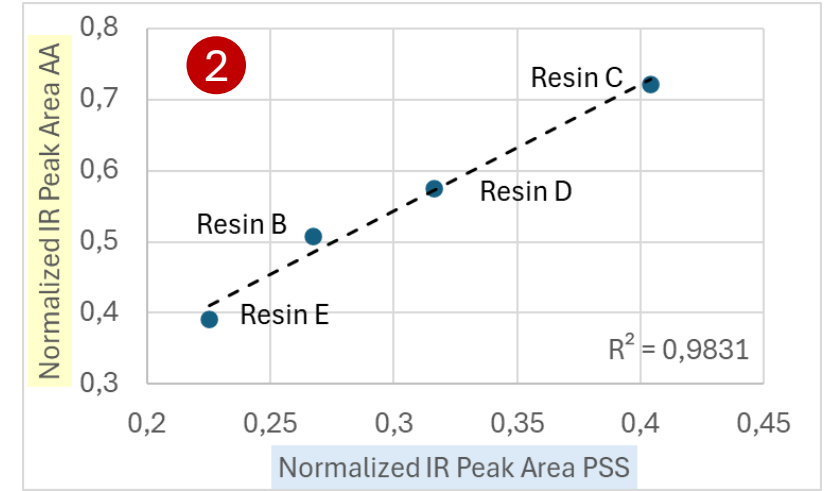
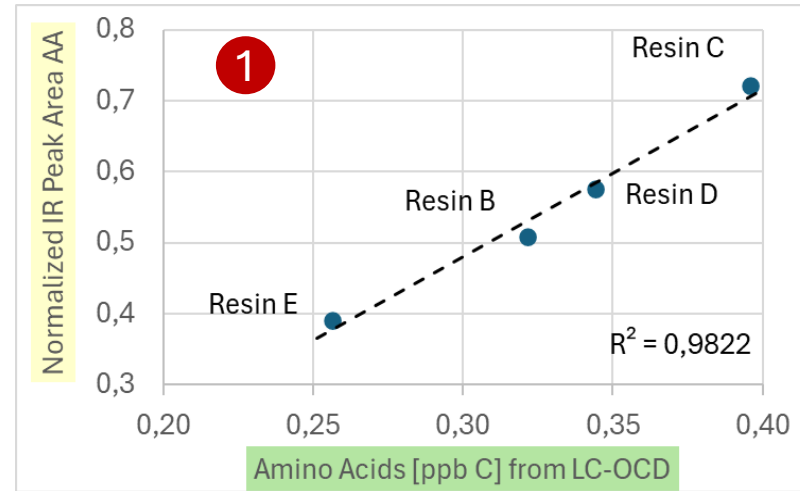
M1 - Total Metals, P1 - 4 nm Particles, P2 - 7 nm Particles, O1 - Online TOC, O2 - LC-Amino Acids

AGENDA

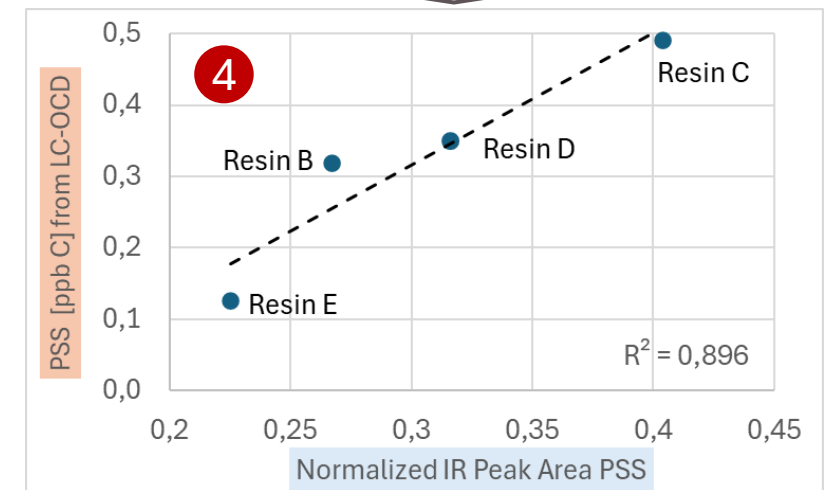
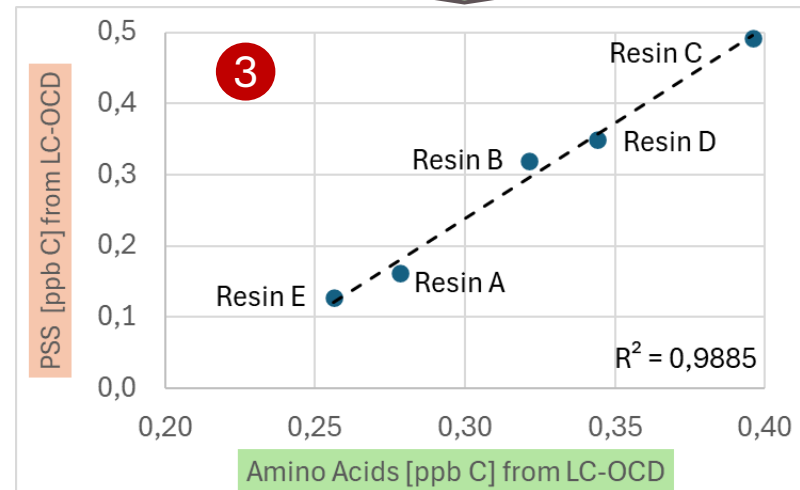
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AMINO ACIDS VS PSS

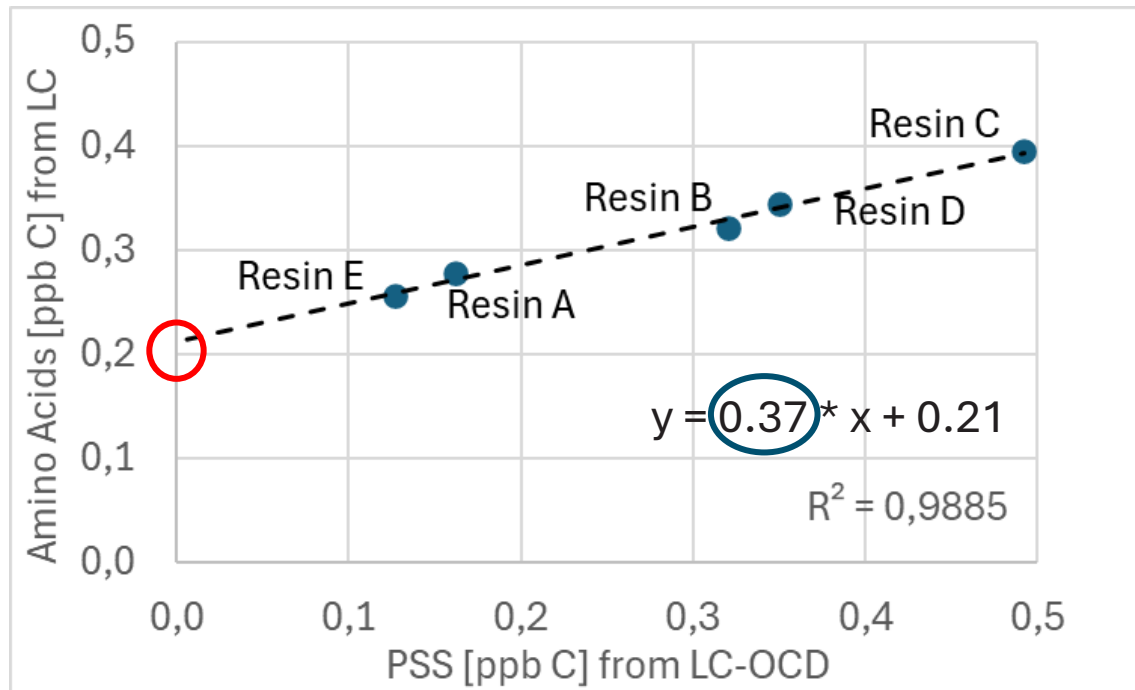
- 1 Data for Amino Acids from FTIR and LC are very well aligned
- 4 Data for Polystyrene Sulfonate (PSS) from FTIR and LC are very well aligned



- 3 We also see a strong correlation between PSS and Amino Acids from LC, as well as between PSS and Amino Acids from FTIR
- 2



AMINO ACIDS VS PSS



Resin test data after approx. 3 days rinse time suggest for **ALL** resins, that 0.21 ppb C from Amino Acids can generally be found in the MBIX product **without** link to PSS.

Resin test data after approx. 3 days rinse time suggest for **ALL** resins, that the shedding rates for PSS and Amino Acids are strongly correlated.

The slope of the correlation between AA and PSS is

$$0.37 \text{ AA/PSS or } 2.7 \text{ PSS/AA}$$

For the ion pairing model, PSS molecules ($n * C8$) would then travel with $n * C3$ Amino Acids ...

$$8 / 3 = 2.7$$

➤ This is just a potential conclusion from the data analysis!

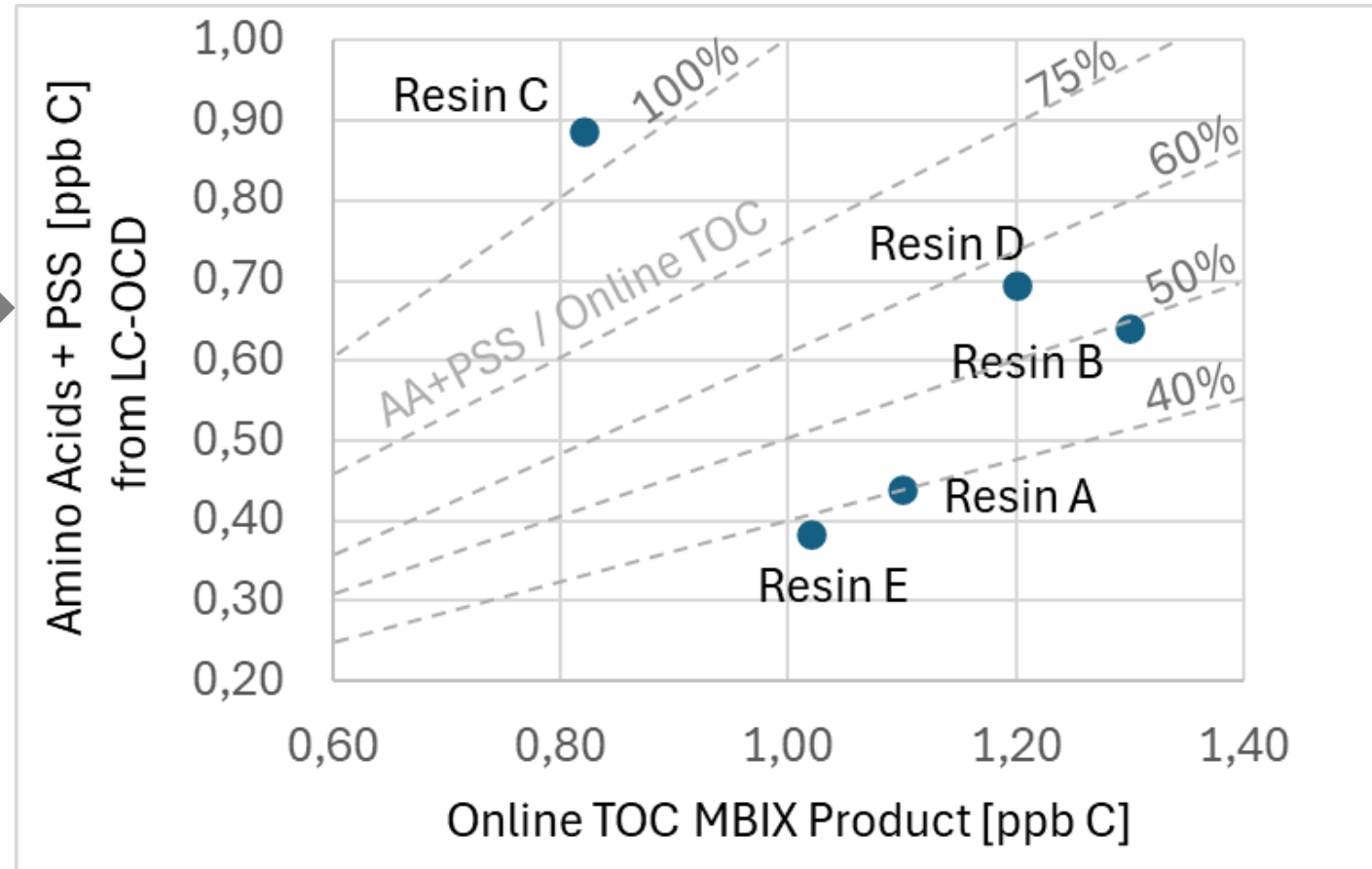
TEST RESULTS – ORGANIC SPECIATION

This graph shows, that the Amino Acid plus the PSS fraction of the DOC from LC is in the range of 50 % of the Online TOC for most of the resins.



Only for resin C, which had the lowest online TOC after rinse down, we found a significantly higher Amino Acids plus PSS content of ~100 % of the online TOC. This would indicate, that from resin C, no other organic contaminants are released.

For all other resins, ~50% of the organic contamination is still unknown.



KEY TAKEAWAYS

- *Mixed bed resins eat and bleed*: We examined the “bleed” of 5 Semi grade MB-resins with state-of-the-art technology.
- There is no “dream” resin if we combine all parameters, but there are clear front runners when it comes to specific parameters.
- Metals were the main differentiator between the five resins, followed by TOC and particles.
- We found a strong correlation between Amino Acids and PSS from LC-OCD and from FTIR, which are seen as potential Particle Precursors (PP’s).
- Cationic and anionic PP’s correlate well with each other, suggesting that they travel together as an ion pair through the MBIX, as previously proposed by Zazzera et al..
- PP’s make up a large part of target TOC (1 ppb).

NEXT STEPS

- Veolia will use the test results as a benchmark for future testing.
- Veolia will keep on working with the vendors of MBIX resins to produce even cleaner resins.
- Veolia will keep on supporting the Microelectronics community to better understand the chemical reaction pathways from particle precursors to particles on wafers.

Thank you !

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